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PATENT APPLICATION 10/044,076



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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

H. Ufuk Alpay et al.

Serial No.:

10/044,076

Date Filed:

January 11, 2002

Group Art Unit:

1756

Examiner:

Mohamedulla, Saleha R.

Title:

DAMAGE RESISTANT PHOTOMASK

CONSTRUCTION

MAIL STOP - NON FEE AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service as Express Mail No. EV334588751US addressed to: Mail Stop - Non Fee Amendment, Commissioner of Patents, Office, P.O. Box 1450, Alexandria, VA 22313-1450, on the date shown below.

Inv Howard

Dear Sir:

RESPONSE TO OFFICE ACTION

In response to the Office Action mailed November 6, 2003, Applicants respectfully submit the following amendments set forth below and request favorable action thereon.

Amendments to Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.